



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

November 29, 2025

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

Cut Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

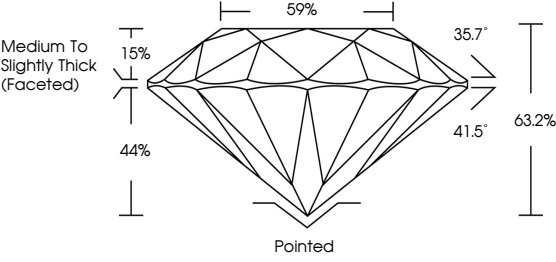
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG752541750

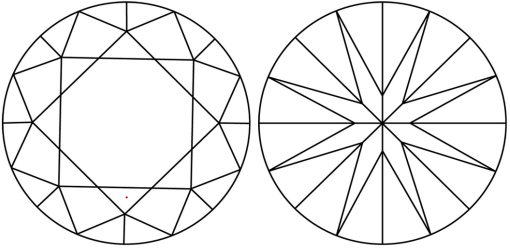
Report verification at [igi.org](#)

PROPORTIONS



Medium To Slightly Thick (Faceted)

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

Sample Image Used



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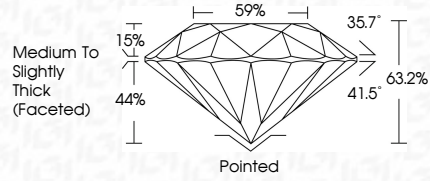
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IGI



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ROUND BRILLIANT

8.03 - 8.07 X 5.09 MM

2.07 CARATS

D

VVS 2

EXCELLENT

63.2%

59%

Medium To Slightly Thick (Faceted)

Pointed

EXCELLENT

EXCELLENT

NONE

IGI LG752541750

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